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著者	渡辺 和雄
journal or publication title	IEEE Transactions on Magnetics
volume	21
number	2
page range	316-319
year	1985
URL	http://hdl.handle.net/10097/47223

PROPERTIES AND PERFORMANCE OF THE MULTIFILAMENTARY
 Nb_3Sn WITH Ti ADDITION PROCESSED BY THE Nb TUBE METHOD

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Abstract

MF Nb_3Sn conductors made by titanium added niobium tube process have been developed for use in high fields. Composites, consisting of Nb-1.0wt.%Ti tube with a copper sheathed tin core inside and a high conductivity copper tube outside, were stacked together up to 264 filaments, then drawn to the final sizes without any intermediate annealings. As workability was further improved by the titanium addition, it was possible to decrease the Cu/SC ratio for the conductor down to 0.67 and to increase the tin concentration up to 30 wt.% in Cu-Sn inside the filament. An enhanced layer growth rate and a slightly increased grain size of Nb_3Sn were observed in the titanium added conductors, compared with those made by use of pure Nb tube. The critical current density at high fields, which was more sensitive for heat-treatment condition, was superior to that of the other conventional processed conductors. Especially, the conductors with 30 % tin content have high critical current density for Nb_3Sn layer and an excellent field dependence of critical current density without copper: 1550 A/mm² at 10 T, 600 A/mm² at 15 T and 350 A/mm² at 17 T. The critical current was also measured in the temperature range 1.88 - 4.2 K. A coil, aiming at 14 T, was fabricated using the conductor with 25 % tin to assure high level performance in practical situations.

Introduction

Nb_3Sn multifilamentary conductors have been developed for high field applications such as plasma confinement system in fusion reactor, hybrid magnets, NMR, laboratory use magnets for physics and so on. Recently, improvements in high field performance for the Nb_3Sn conductors processed by the bronze method have been endeavored by the addition of the third element, for instance Ti, Ta, Ga, Mg or Hf, to the niobium filament and/or to the bronze matrix. Titanium is known as one of the most significant elements among additions.^{1,2}

On the other hand, the conventional Nb_3Sn conductor processed by the bronze method has imperfections: (i) necessary intermediate annealings due to work hardening of the bronze, (ii) low tin concentration (13-14 wt.%) and (iii) necessary diffusion barriers to protect the copper stabilizer. In order to eliminate those drawbacks, the Nb_3Sn conductor processed by the Nb tube method has been developed.^{3,4} The method offers conductors of tubular niobium filaments, each filled with a copper sheathed tin inside and embedded in a matrix of high conductivity copper outside. In the present method, (i) intermediate annealings are unnecessary because the composite which consists of pure metals mitigates the work hardening during the reduction, (ii) high tin concentration inside the niobium filament is possible and (iii) the niobium tube filaments play a role in diffusion barrier during Nb_3Sn formation.

Manuscript received September 10, 1984

As a further modification, titanium addition to the tubular niobium has been carried out to enhance high field performance for the conductors processed by the Nb tube method.

This paper gives the results obtained from conductors fabricated using the Ti added Nb tube method, particularly, critical current densities and grain morphology in relation to the heat treatment condition and the tin concentration inside the tubular niobium. Preliminary results, obtained from a coil wound with the present conductor, are also described.

Fabrication Process

A single core was fabricated using a Nb-1.0wt.%Ti tube with copper sheathed tin inside and copper outside. For fabricating MF conductors, single core wires were bundled, together 7 to 264 filaments in a copper tube, then drawn down to final sizes without any intermediate heat treatments and finally submitted to a reaction heat-treatment to form Nb_3Sn . The present method can vary tin concentration widely inside the filament, depending on the copper sheath thickness. Data on fabricated conductors are listed in Table I and a cross-sectional view of A1 conductor is shown in Fig. 1. As workability was further improved by the titanium addition, Cu/SC ratio was able to decrease down to 0.67 for conductors B and D, and tin content could be increased up to 30 wt.% in copper sheathed tin for conductors D and F1-3. A3 conductor was reduced to a rectangular cross-section for ease in winding a coil from a 1 km length.

Table I. Data on fabricated conductors

Conductor Number	Wire Diameter (mm)	Number of Filaments	Filament Diameter (μ m)	Cu/SC ratio	Tin Contents (wt.%) in Cu-Sn
A1	0.87	264	36.2	1.2	25
A2	0.65x1	264	~36	1.2	25
A3	1.25x25	264	~86	1.2	25
B	1.17	37	150	0.67	25
C	1.05	37	120	1.0	25
D	1.4	37	180	0.67	30
E1	0.54	7	120	1.98	25
E2	0.69	7	150	1.98	25
E3	0.80	7	180	1.98	25
F1	0.54	7	120	1.98	30
F2	0.69	7	150	1.98	30
F3	0.80	7	180	1.98	30

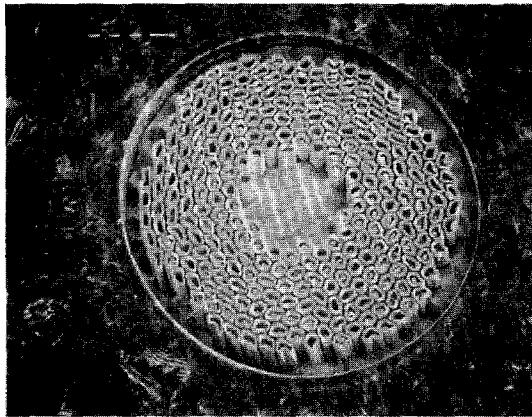


Fig. 1 Cross-sectional view of a conductor processed by the modified Nb tube method (Al conductor)

Experimental Procedure

The fabricated conductors were heat-treated in the range of 675 - 775°C for 1 - 312 h to form the Nb₃Sn layer inside the niobium tube. The grain morphology was studied using an SEM and an optical microscope. The composition profile was analyzed by an EPMA. Critical currents (I_c) were measured in the transverse magnetic field from 8 to 20 T at 1.88 - 4.2 K using 1 μ V/cm criterion. The hybrid magnet, which consists of a water cooled coil and a superconducting coil at Tohoku University, was used for I_c measurement above 15 T.

Conductor Characteristics

Nb₃Sn Layer

The effects of Ti addition on the layer growth rate were investigated. Figure 2 shows Nb₃Sn layer thickness versus heat-treatment time for Al conductor,

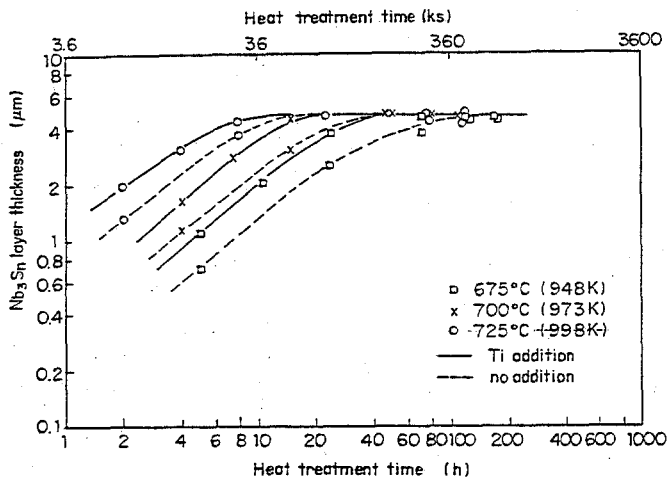


Fig. 2 Dependence of the Nb₃Sn layer thickness on the heat-treatment time

compared with a pure Nb₃Sn conductor with the same configuration. In the wires with Ti addition, the time required for reaching the saturated layer thickness was 1/3 - 1/4 of the time for the pure Nb₃Sn. The result shows that Nb₃Sn formation reaction occurred more actively by the titanium addition.

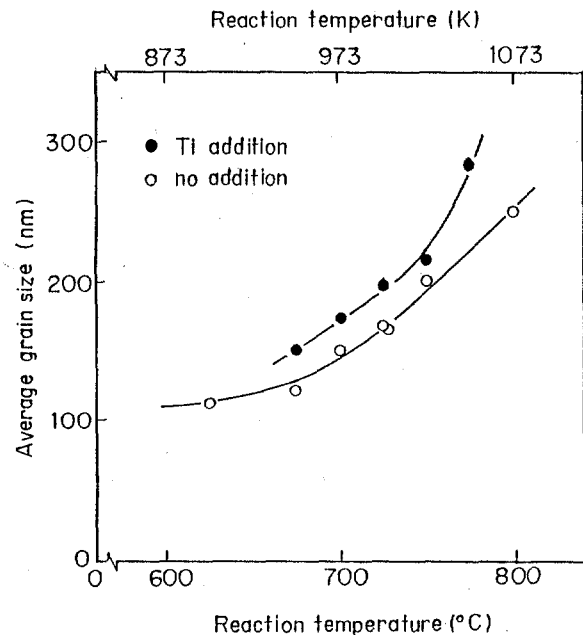


Fig. 3 Average grain size for Nb₃Sn plotted against the reaction temperature

Figure 3 shows Nb₃Sn grain size versus heat-treatment temperature. The Nb₃Sn grains become coarse with increasing temperature. The grain size for titanium addition is slightly larger than the pure Nb₃Sn conductor.

Titanium diffusion in the composite was studied by an X-ray microanalyzer for reacted Al conductor. The results are shown in Fig. 4. Titanium diffused only into the Nb₃Sn layer (1.1 wt.% Ti in Nb₃Sn) and was not traced in the copper stabilizer and reacted Cu-Sn alloy inside the filament. In the Nb tube method, the titanium diffusion mechanism is thought to be the same as that for the conductor by the bronze method.¹ Critical current density (Nb₃Sn layer) at high fields increases as titanium content in the Nb₃Sn layer increases, for the range of 0.5 - 1.5 wt.% Ti in Nb₃Sn, in the case of titanium addition to the niobium core.¹ As 1.1 wt.% Ti in Nb₃Sn for the Nb tube method is larger than 0.5 % for the ordinary bronze processed wire, high performance is expected at higher fields for the Nb tube processed conductor.

Critical Current Density

25 wt.% Sn conductor: In order to estimate the optimum heat-treatment condition for Al conductor, characteristics of critical current density without copper (J_c) vs. heat treating time at several heat-treatment temperatures were obtained, as shown in Fig. 5. It can be seen that the optimum heat-treatment time decreases with increasing heat-treatment temperature. J_c peaks at low fields were not observed remarkably as compared with the ones at high fields. It was considered that J_c is more sensitive for heat-treatment condition at high fields than at low fields.

The magnetic field dependence of J_c in Al conductor heat-treated for 120h at 700°C is shown in Fig. 6, compared with pure Nb₃Sn conductor by the same process. Critical current density without copper of the conductor with 25 wt.% Sn was superior to pure Nb₃Sn at high fields and also to the highest J_c obtained in the conductors using the other conventional method.^{1,2} J_c values for conductors E1 and E2 treated for 240 h at 725°C, which were also plotted in Fig. 6, became slightly

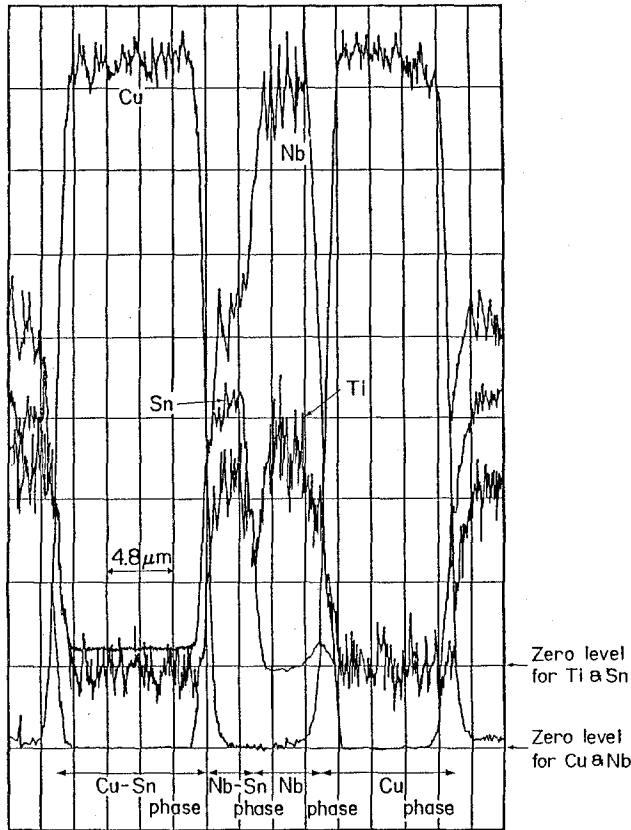


Fig. 4 Composition profile on the cross-section of Al conductor

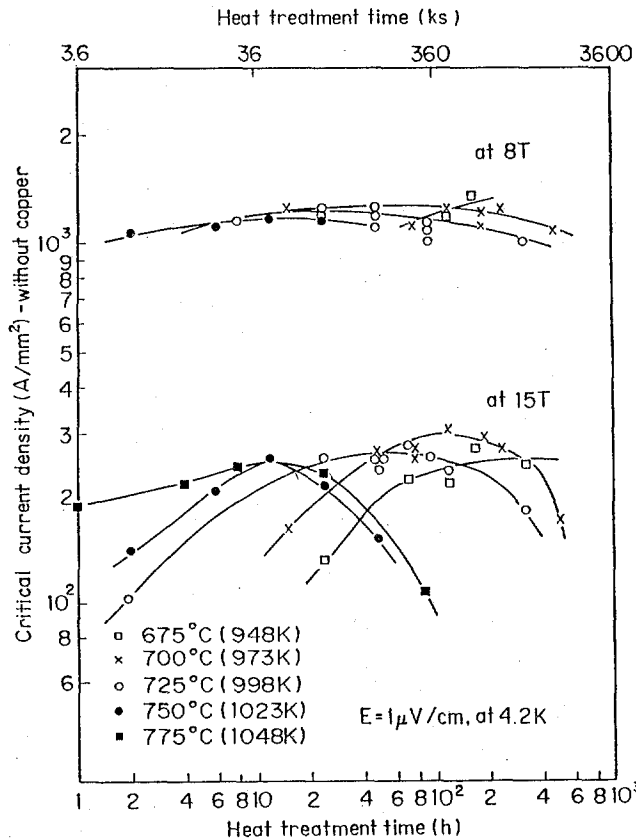


Fig. 5 Critical current density vs. heat treatment time at several heat treatment temperatures

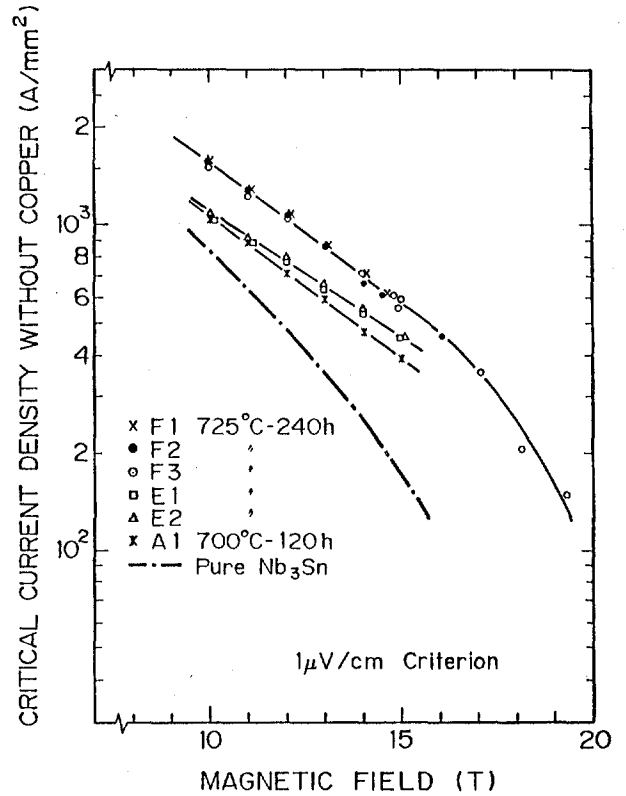


Fig. 6 Field dependence of J_c in various conductors

higher than that for Al at high field region: 450 A/mm² for E1&2 and 390 A/mm² for Al at 15 T in contrast with 1050 - 1100 A/mm² at 10 T for Al and for E1 and E2. Upper critical fields (H_{c2}), extrapolated from Kramer's plot, were obtained to investigate this difference further in detail: 26.5 T for E1 and for E2 and 24.5 T for Al conductor. Since E1 and E2 conductors were subjected to longer term heat-treatment, it is considered that H_{c2} increases and subsequently high J_c at high fields is obtained as compared with Al.

30 % Sn conductor: High tin content (30 wt.%) conductors, F1-3, have performed excellent field dependence of critical current density: 1550 A/mm² at 10 T, 600 A/mm² at 15 T and 350 A/mm² at 17 T, as also shown in Fig. 6. Those values are larger than those for the ECN-Holec wire⁽⁵⁾ at high fields above 15 T and are about 50 % up from those for conductors E1 and E2 with 25 % Sn content. H_{c2} obtained for 30 % tin conductor from the Kramer's plot was 26.5 T, which was the same as that for 25 % tin conductor. From experimental results obtained for Nb₃Sn layer thickness for 30 % tin conductor, which has the same thickness as that for 25 % tin conductor, it is considered that high J_c in 30 % conductor would be caused by J_c increase in Nb₃Sn layer.

J_c below 4.2 K: For Al conductor heat-treated for 72 h at 725°C, field dependence of J_c was studied below 4.2 K, as shown in Fig. 7. Normalized critical current, $I_c(2.13 K)/I_c(4.2 K)$, which increased with increasing the magnetic field, is 1.3 at 10 T and 1.5 at 15 T. The H_{c2} increase from 4.2 K to 2.13 K, was 2.5 T, which was obtained from those data using Kramer's plot.

High Field Solenoid Fabrication

In order to check the feasibility of fabricating a long wire, which is necessary for practical application,

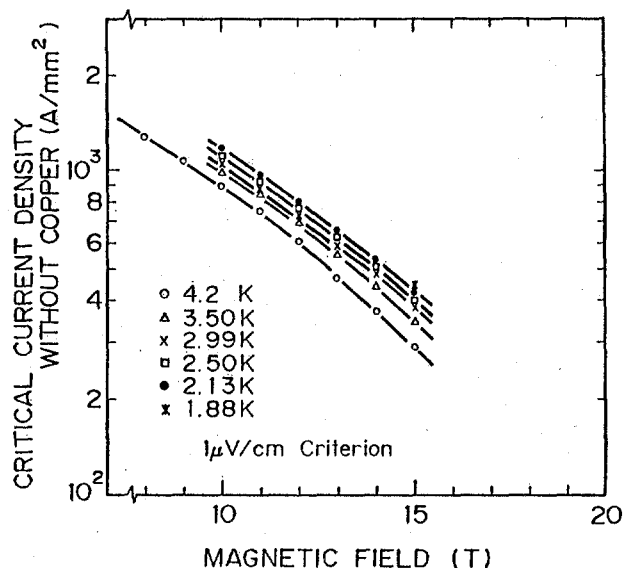


Fig. 7 Field dependence of J_c below 4.2 K in Al conductor heat-treated for 72 h at 725°C

the authors fabricated a high field (13–14 Tesla) solenoid with the A3 conductor given in Table I. The solenoid is 40 mm in inner diameter, 140 mm in outer diameter and 140 mm in length. The conductor cross section was 1.25 x 2.5 mm²; individual filament size was 86 μm. The magnet utilized a react after wind process; therefore, the conductor was insulated with quartz-fiber braids, while the coil form was insulated with heat resistant ceramic-fiber papers. After a heat treatment of 725°C x 181 h, the magnet was vacuum impregnated with epoxy resin. The solenoid was inserted into a bore of a NbTi backup magnet; 159 mm in inner diameter, 276 mm in outer diameter and 295 mm in length. Parameters for both magnets are listed in Table II. The magnet system was designed to generate 14.3 T at maximum, as shown in Fig. 8. Actually, it reached 13.6 T in a recent experiment in our laboratory, which is indicated by the closed circle in the figure.

Conclusions

The modified Nb tube method, titanium addition to the niobium tube, offers MF Nb₃Sn conductors with good workability and high critical current density. Several types of conductors have been fabricated, such as 0.67–1.98 Cu ratios and tin contents of 25 wt.% and of 30 wt.%. The present conductors were heat-treated for 1–312 h at 675–775°C to study grain morphology and

Table II. Coil parameters

Items	Nb ₃ Sn coil	NbTi coil
Conductors		
Conductor cross section (mm ²)	1.25 x 2.5	1.2 x 2.4
Copper ratio	1.2	1.0
Insulation	Quartz fiber braids	Formvar
Coil		
Inner diameter (mm)	40	159
Outer diameter (mm)	140	276
Coil length (mm)	140	295

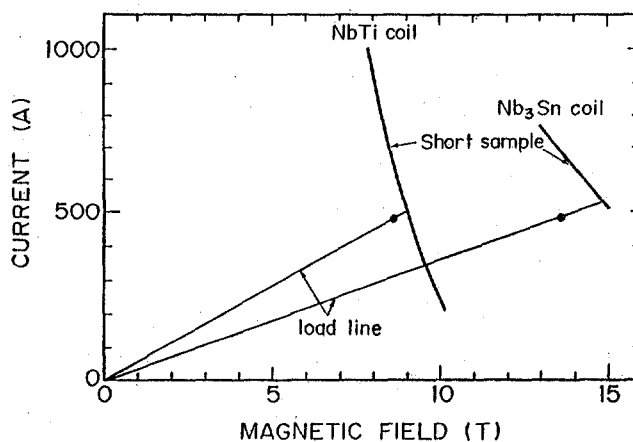


Fig. 8 Coil characteristics

superconductivity. Subsequently, Nb₃Sn layer thickness, grain size, composition profile and critical current density at the field range of 8–20 T and at the temperature range of 1.88–4.2 K were measured for the present conductors. Nb₃Sn layer growth rate was three or four times as large as the pure Nb₃Sn. Titanium in the composite diffused only into Nb₃Sn layer (1.1 wt.% Sn in Nb₃Sn after reaction) and was not traced in the copper stabilizer and reacted Cu-Sn inside the filament.

J_c became more sensitive for heat-treatment condition with increasing the magnetic field. J_c for 25 % tin conductor was superior to pure Nb₃Sn at high fields and also the highest J_c obtained in the conductors using the other conventional processes. Conductors with high tin content (30 %) have shown an excellent field characteristic of J_c values, such as 1550 A/mm² at 10 T, 600 A/mm² at 15 T and 350 A/mm² at 17 T, which are larger than those for ECN-Holec wires at high fields above 15 T and about 50 % up from those for conductors with 25 % tin content. J_c below 4.2 K was also measured. Finally, the coil fabrication, aiming at 14 T, was achieved using the conductor with 25 % tin content to assure high performance of practical conductors.

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